2016

M.Sc.

## 2nd Semester Examination

**ELECTRONICS** 

PAPER-ELC-204

Full Marks: 50

Time: 2 Hours

The figures in the right-hand margin indicate full marks.

Candidates are required to give their answers in their own words as far as practicable.

Illustrate the answers wherever necessary.

Answer Q. No. 1 and any three from the rest.

- 1. (a) Prove that for an unbiased P-N diode as Fermi level is constant throughout the function.
  - (b) Discuss the differences between the input ionization and field ionization of a P-N function diode.
  - (c) For a metal-semiconductor diode prove that  $a\phi_{\rm Ba} + a\phi_{\rm Bo} = {\rm Eg.}$

- (d) What do you mean by surface state pinning effect in a Metal-semi conductor function?
- (e) Determine dopping concentration,  $N_{\rm D}$  of the semiconductor side of a metal n-type Schottky diode from function capacitance.
- (a) For an abrupt P-N junction derive the expression for depletion Layer width.
  - (b) Define depletion and diffusion capacitance.
  - (c) For a linearly graded function prove that built in potential is proportional with the third power of depletion Layer width.

4+2+4

3. (a) For a metal-semiconductor function show that the barrier height  $\phi_{\rm Bn}$  can be expressed as

$$\phi_{Bn} = C_2 \left(\phi_{Cn} - x\right) + \left(1 - C_2\right) \left(\frac{E_g}{9} - \phi_0\right) - \Delta \phi$$

where the symbols have their usual meaning. Simplify the above expression for low and high value of interface state density.

(b) How can you measure  $\phi_{Bn}$  using current-voltage measurement method?

(6+2)+2

- 4. (a) In a metal semiconductor field effect transistor (MESFET) prove that the transconductance in the saturation region is equal to the drain conductance Ce in the linear region.
  - (b) What do you mean by Normally 'OFF' and Normally 'ON' MESFETs?
  - (c) For a MESFET operated in velocity saturation region prove that gm/cgs = v<sub>a</sub>Z.

5+2+3

- 5. (a) Draw the Eber-Molls model of a transistor and derive the expression of emitter, base and collector current.
  - (b) Draw the Gummel-Poon model of a transistor and indicate different parameters.

Discuss how accuracy in this model is paid off by its complexity?

6+(3+1)

6. (a) Explain how a negative resistance occurs in a Rend diode? Write down some suitable applications of IMPATT diode.

(b) Prove that in a SCR the expression of anode current  $(I_A)$  can be given by

$$I_A = \frac{\alpha_2 I_g + I_{CO_1} + I_{CO_2}}{1 - (\alpha_1 + \alpha_2)}$$

where the symbols have their usual meanings.

$$\left(3\frac{1}{2}+1\frac{1}{2}\right)+5$$

[Internal Assessment — 10 Marks]